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In the Claims

1. (currently amended) Arrangement comprising a support body and a substrate holder

which is supported thereon and driven in rotation, the a gas bearing and the a rotary

drive being formed by means of gas flowing into the separating gap between support

body and substrate holder from nozzles, characterized in that the support body and the

substrate holder are formed as rings, and the support body includes a ring bead which

projects into a ring recess in the substrate holder.

2. (currently amended) Arrangement according to Claim 1 or in particular according

thereto, characterized in that the rings rest on top of one another in a self-centering

fashion.

3. (cancelled)

4. (currently amended) Arrangement according to Claim 1 or in particular according

thereto, characterized in that the substrate is supported on the ring which is driven in

rotation only by means of its edge.

5. (currently amended) Arrangement according to Claim 1 or in particular according

thereto, characterized in that the substrate rests on the ring with minimal contact, pref-

erably only on the tips of needle-like protuberances.

6. (currently amended) Arrangement according to Claim 1 or in particular according

thereto, characterized in that the nozzles open out into arcuate grooves, in particular

arcuate grooves.

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7. (currently amended) Arrangement according to Claim 1 or in particular according

thereto, characterized in that the nozzles open out into arcuate grooves with alternating

preferred directions of gas flow streams, said streams flowing in opposite directions in-

side them alternate.

8. (currently amended) Arrangement according to Claim 1 or in particular-according

thereto, characterized by oppositely directed driving gas streams for rotationally bearing

and rotationally driving the rotating ring.

9. (currently amended) Arrangement according to Claim 1 or in particular according

thereto, characterized in that the substrate is can be radiation-heated from below

through the rings.

10. (currently amended) Arrangement according to Claim 1 or in particular according

thereto, characterized in that the support body and/or the substrate holder consist of

quartz or ceramic material.

11. (currently amended) Arrangement according to Claim 10 or in particular according

thereto, characterized in that the rotationally driven ring has a low heat absorption.

12. (currently amended) Arrangement according to Claim 11 or in particular according

thereto, characterized in that the arrangement is part of a device for the heat treatment

of semiconductor wafers.

13. (currently amended) Device for the in particular rapid heat treatment of in particular

flat objects, such as semiconductors, glass or metal substrates, having a support body

and a substrate holder which is supported thereby in such a manner that it can be

driven in rotation and on which the flat object can be placed, it being possible to produce a gas cushion beneath the substrate holder by means of gas which emerges from nozzles which open out into a separating gap between support body and holding body, on which gas cushion the substrate holder rests in such a manner that it is driven in rotation by directed gas streams, characterized in that the support body and the substrate holder are formed as rings, the support body includes a ring bead which projects into a ring recess in the substrate holder, the support body and/or the substrate holder consist of quartz or ceramic material, the rotationally driven ring has a low heat absorption, and the arrangement is part of a device for the heat treatment of semiconductor wafers. and the device is formed in particular according to Claim 12.

- 14. (new) Arrangement according to Claim 1, wherein the nozzles open out into the separating gap and open out into grooves.
- 15. (new) Arrangement according to Claim 14, wherein said grooves are formed in the mating surface of said support body opposite the mating surface of said substrate holder.
- 16. (new) Arrangement according to Claim 15, wherein each nozzle opens out into the proximal end of a corresponding groove.
- 17. (new) Arrangement according to Claim 16, wherein gas emerging from each nozzle flows in a preferred direction from the proximal end of each groove to the distal end of each groove.

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18. (new) Arrangement according to Claim 17, wherein said grooves are distributed on

the surface of said support body such that there are alternating preferred directions of

gas flows.

19. (new) Arrangement according to Claim 18, wherein said preferred directions are

opposite directions.

20. (new) Arrangement according to Claim 19, wherein a portion of said grooves are

formed in the surface of said ring bead.

21. (new) Arrangement according to Claim 20, wherein said grooves are arcuate

grooves.